# Overview of the ATLAS Insertable B-Layer (IBL) Project

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on behalf of
the ATLAS
Collaboration

5th Sept. 2013,
9th International
"Hiroshima"
Symposium,
Hiroshima, Japan.

# Introduction

- Motivation
- Overview

# Layout

- Sensors: Planar & 3D
- Testbeam Results
- FE-I4 Readout Chip

# Production

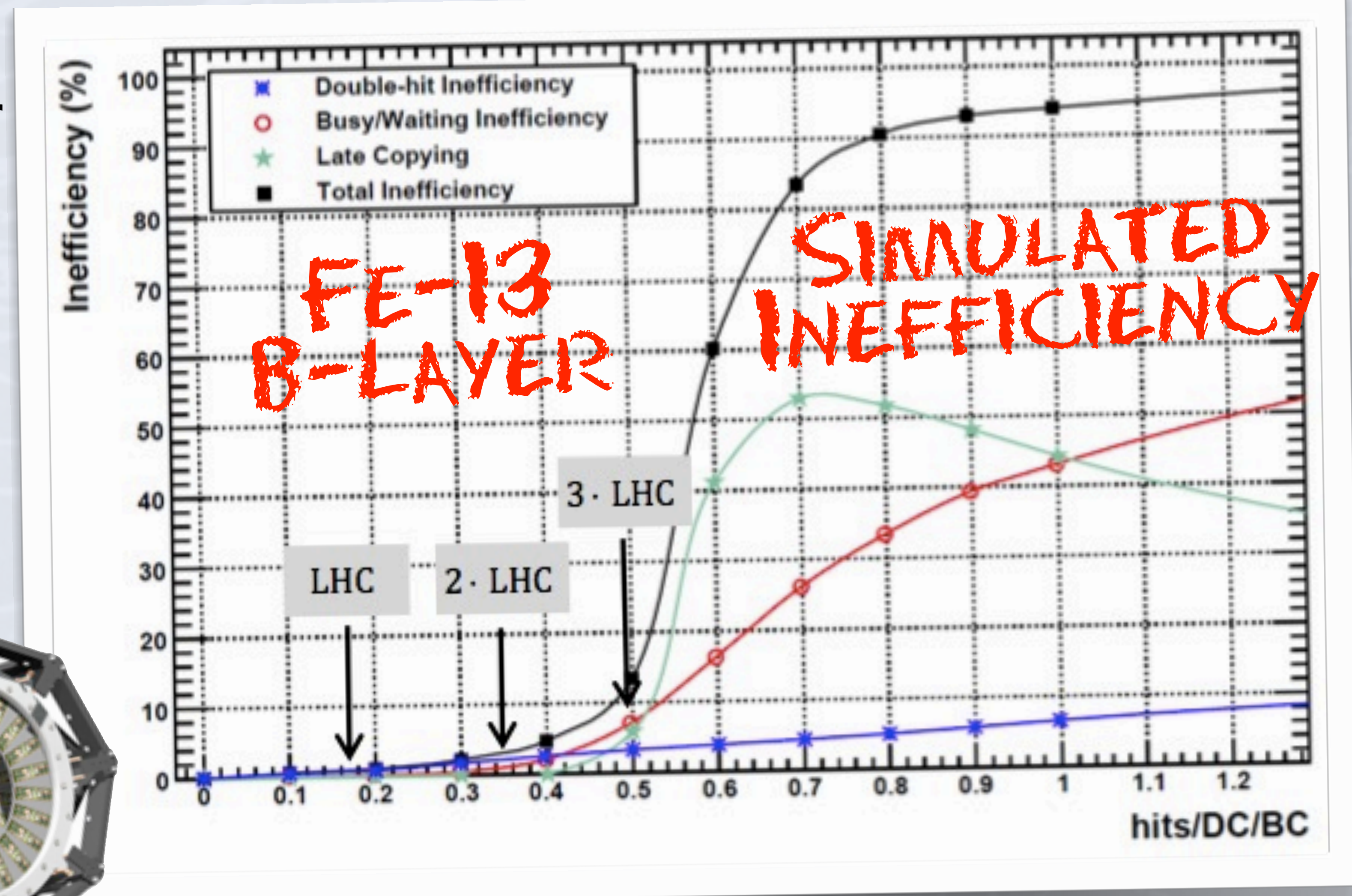
- Modules & Staves
- Quality Assurance

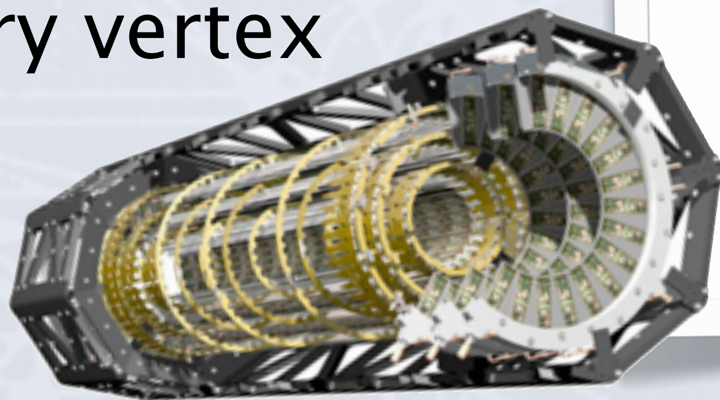
# Conclusions

# Insertable B-Layer Motivation Tell me why!



- Pixel Detector showed great performance over last years (see Timon Heims talk)
- Essential for:
  - b-tagging,
  - tracking and
  - primary vertex

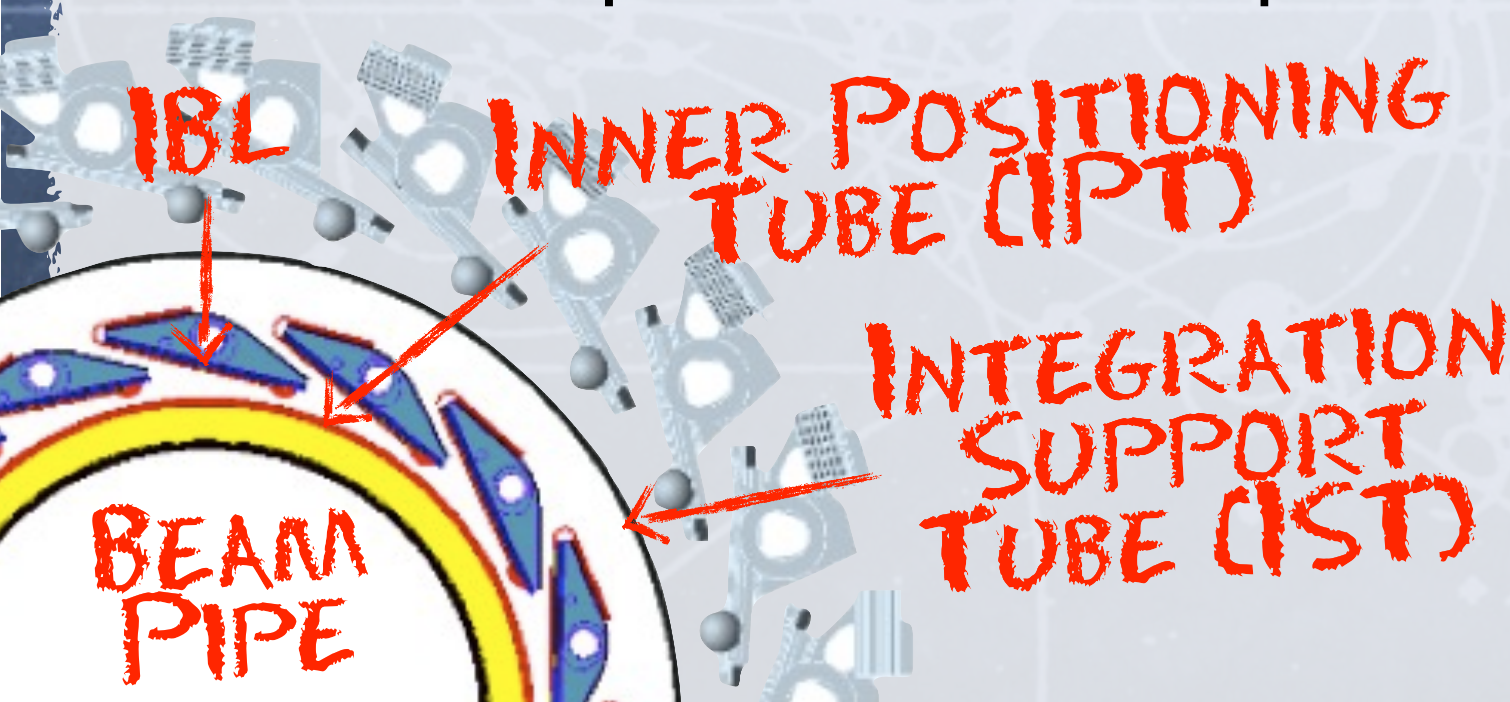


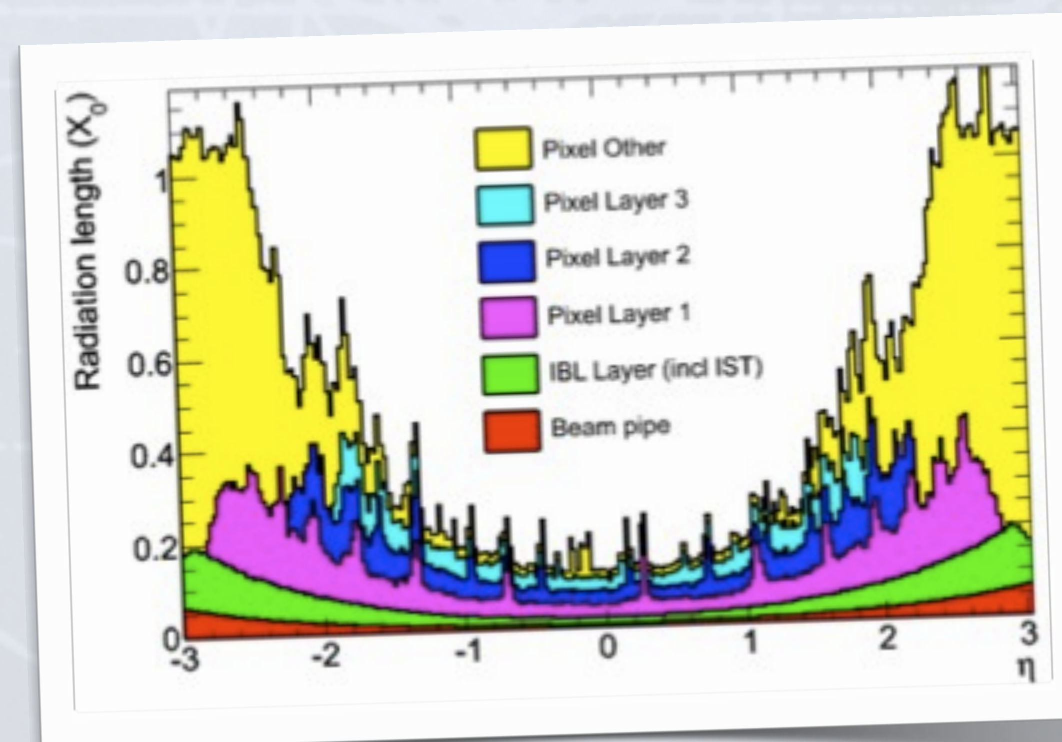



- Large Hadron Collider upgrade: √s 8 TeV → 14 TeV
  - LHC luminosity of $10^{34} cm^{-2} s^{-1}$ will increase by factor 2-3
  - FE-I3 inefficiency in B-Layer will reach 5% to 10%
- IBL aim: compensate inefficiency & radiation damage losses

# Insertable B-Layer Overview THE BASICS

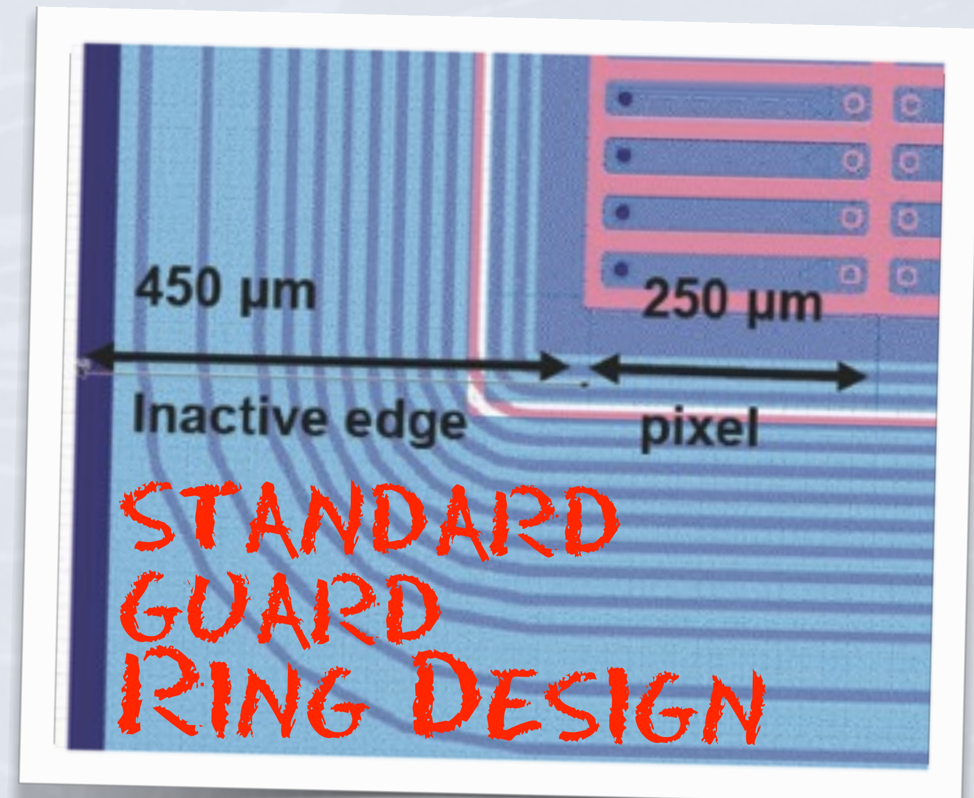
- New 4th pixel silicon barrel layer with r = 3.3 cm, 12 MegaPixel
- Needs small radius (r = 2.35 cm) beam pipe
- Inner & outer carbon support tubes (IPT & IST)
- 14 staves with $\Phi = 14^{\circ}$ tilt angle & no z overlap
- Radiation Length < 1.9% $X/X_0$ using: carbon foam support, Titanium cooling tubes, $CO_2$ cooling
- High track density small radius & high luminosity:
  - increase radiation hardness: $5 \cdot 10^{15}$ $n_{eq}/cm^2$ & 250 MRad TID
  - investigate new sensor technologies: 3D & planar slim edge
  - use new pixel readout chip: FE-I4

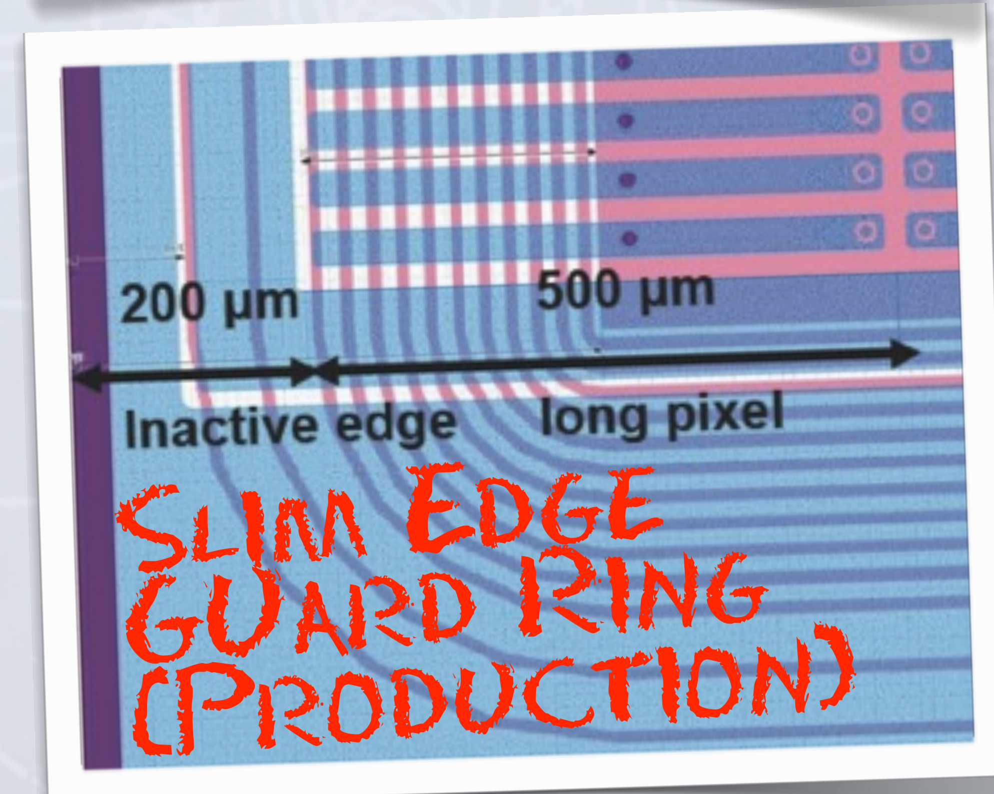


# IBL Planar Sensors SHORT PIXELS & SLIM EDGE

- Planar n-in-n oxygenated Si sensor
- Pixel electrodes on surface of bulk
- Proven ATLAS Pixel Detector technology and vendor: CIS
- Very high yield (90% accepted for IBL production)
- Reduced:
  - Pixel size 400 μm → 250 μm
  - Thickness 250 μm → 200 μm
  - Inactive edge 450 μm → 200 μm
  - Depletion voltage: 35 V
- Increased radiation hardness: $5 \cdot 10^{15}$ $n_{eq}/cm^2$ & 250 MRad TID
- 26880 pixel per FE-I4 readout chip

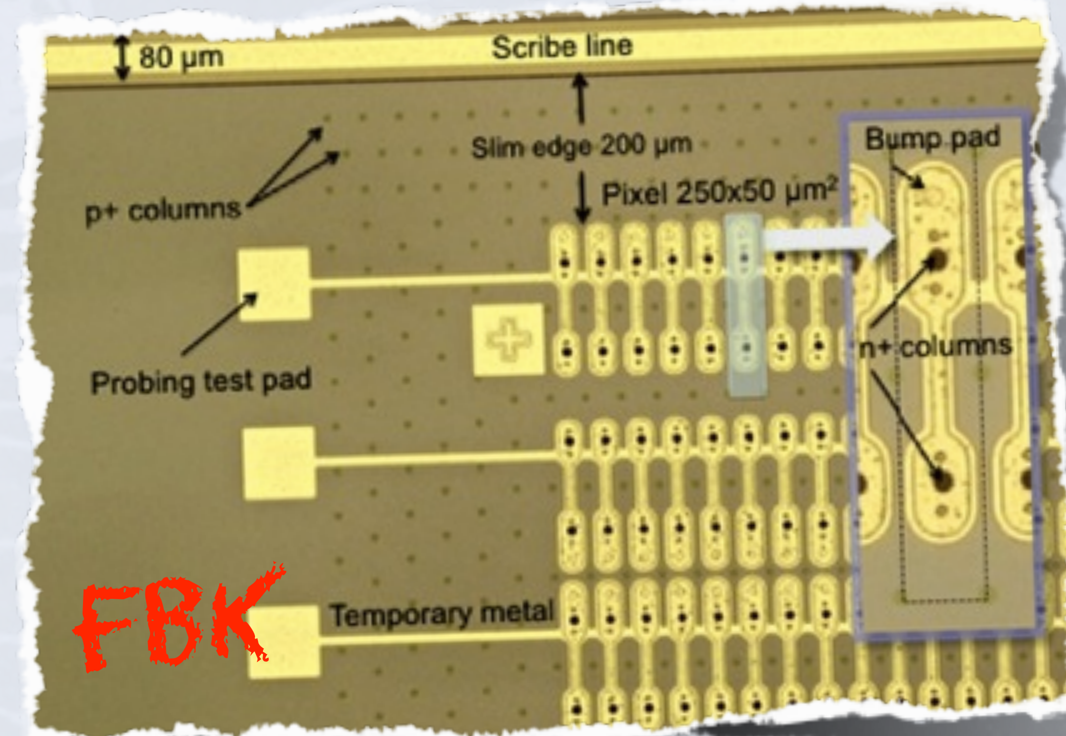


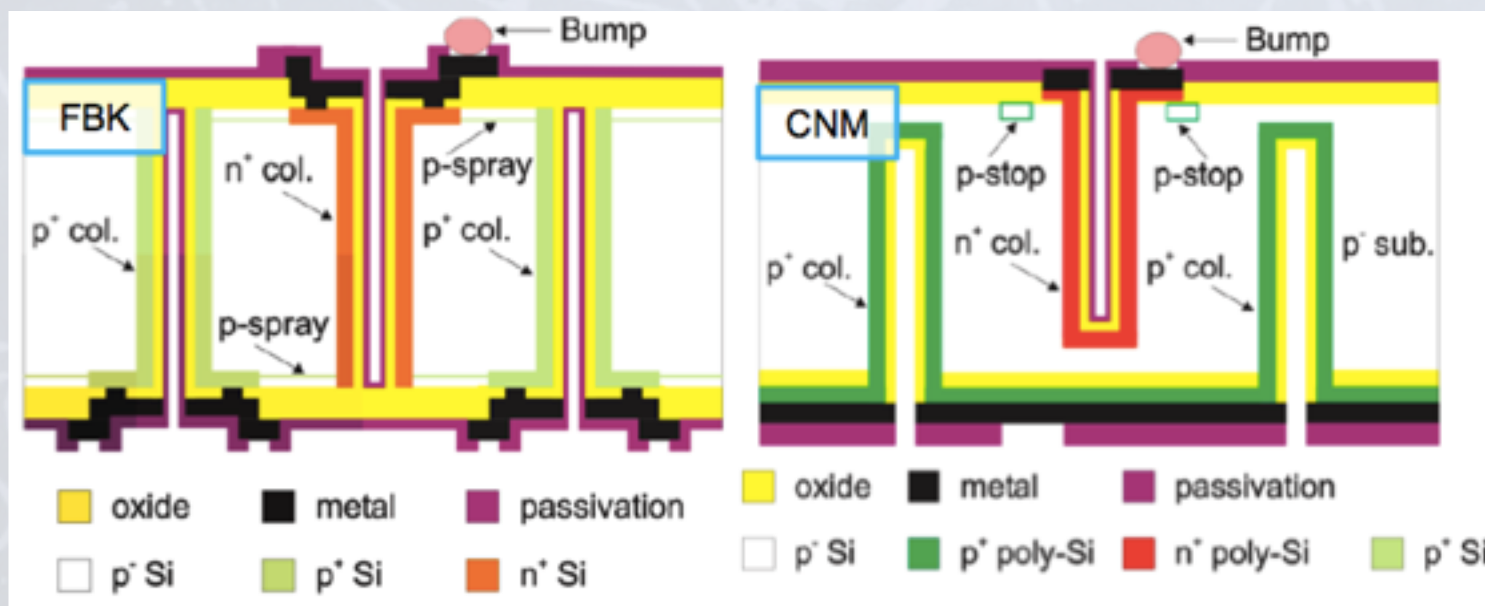



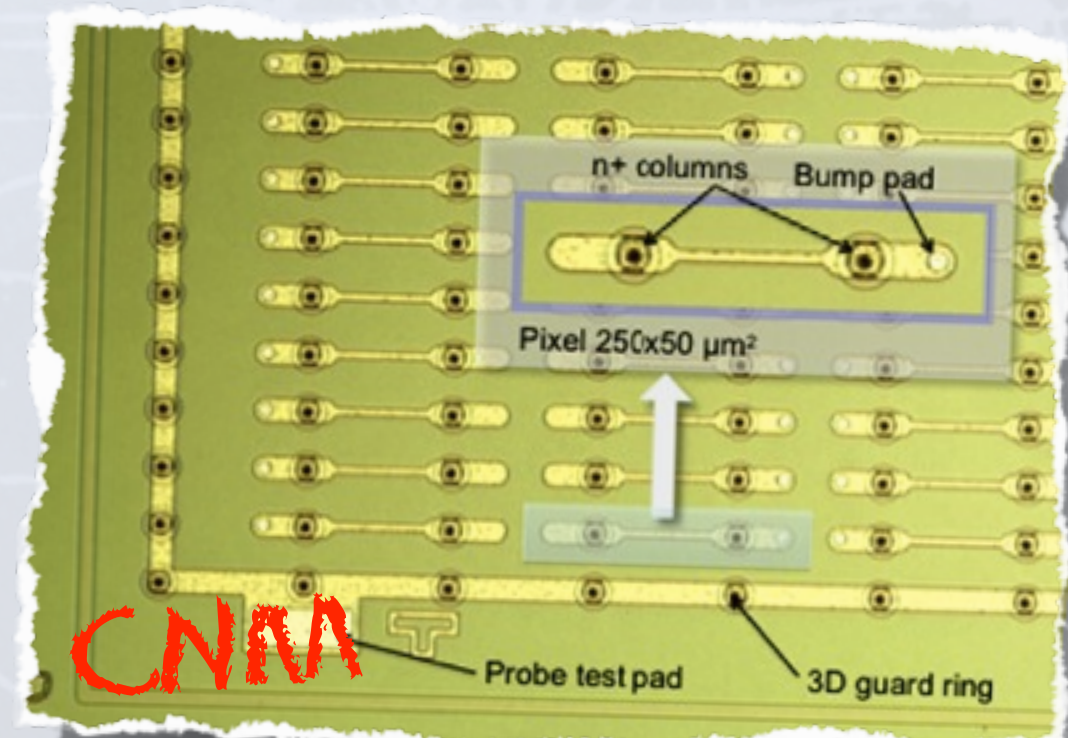
# IBL 3D Sensors FBK & CNM



- 3D double sided silicon sensors with vertical 2E electrodes used at high eta reduce collection time & depletion voltage
- 230 μm thickness
- Depletion voltage: 15 V
- Two 3D sensor vendors
- Acceptable yield (60% for IBL)



# Testbeam Slim Edges PLANAR & 3D

- Several testbeams at DESY & CERN
- High efficiency confirmed with EUDET telescope runs
- results as expected for resolution, cluster size, and time-over-threshold (TOT) based Landau shape

Edge Pixel

IRRADIATED PLANAR

Long pixel [µm ]

Edge Pixel

JINST 7 (2012) P11010

IRRADIATED 3D CNM

Long pixel [µm ]

# Testbeam Efficiencies Planar & 3D

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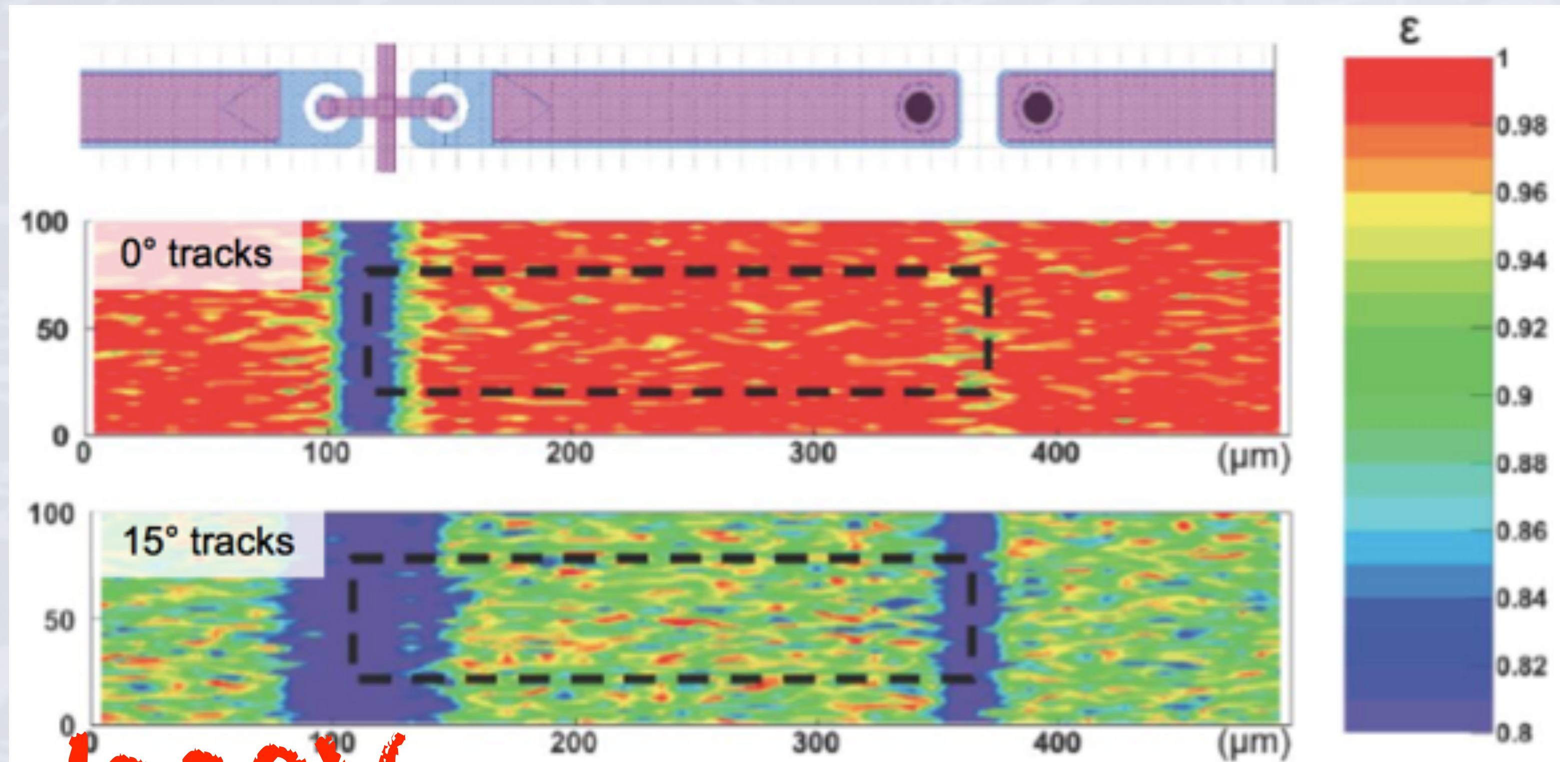
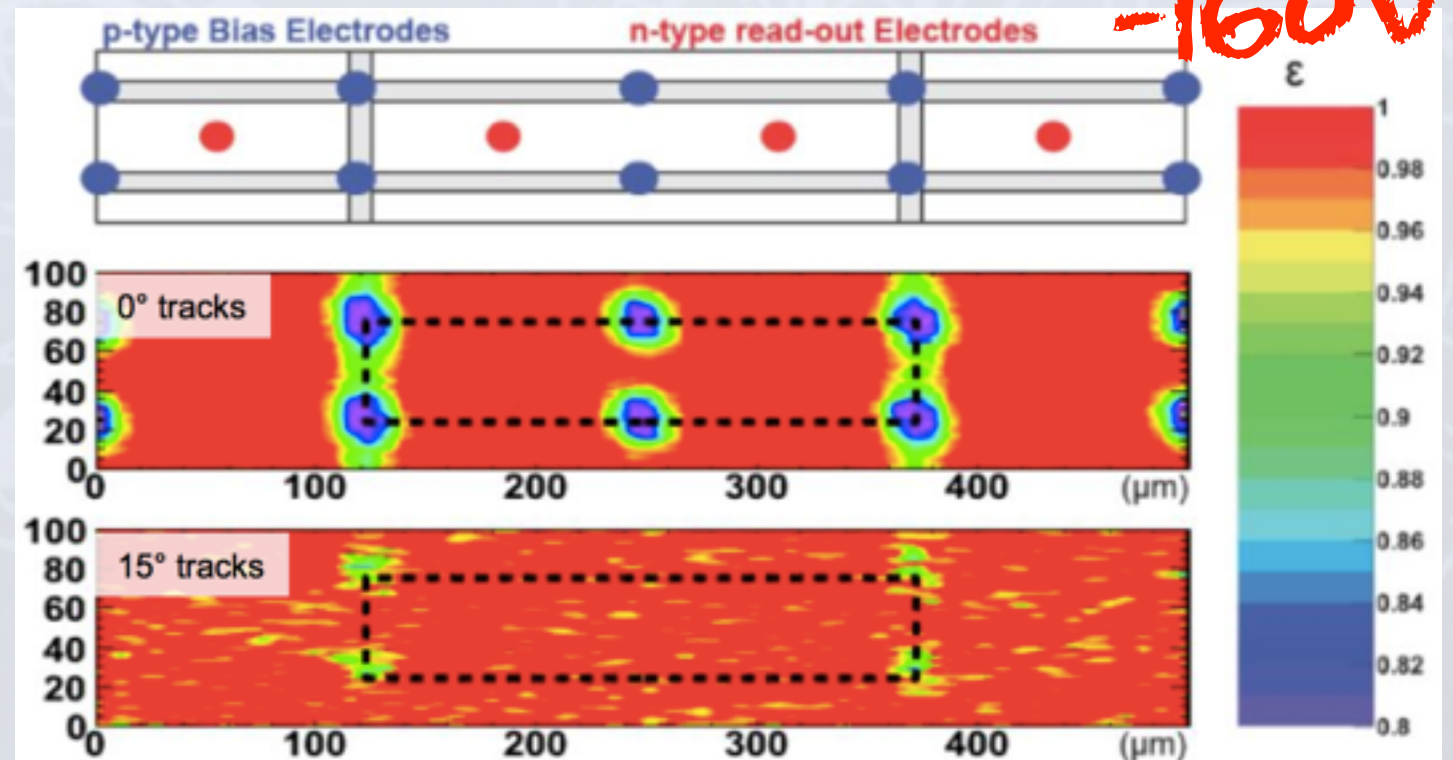



## Irradiated Planar

- $6 \cdot 10^{15}$ $n_{eq}/cm^2$
- 96.9% overall efficiency at 0°
- 86.4% overall efficiency at 15°



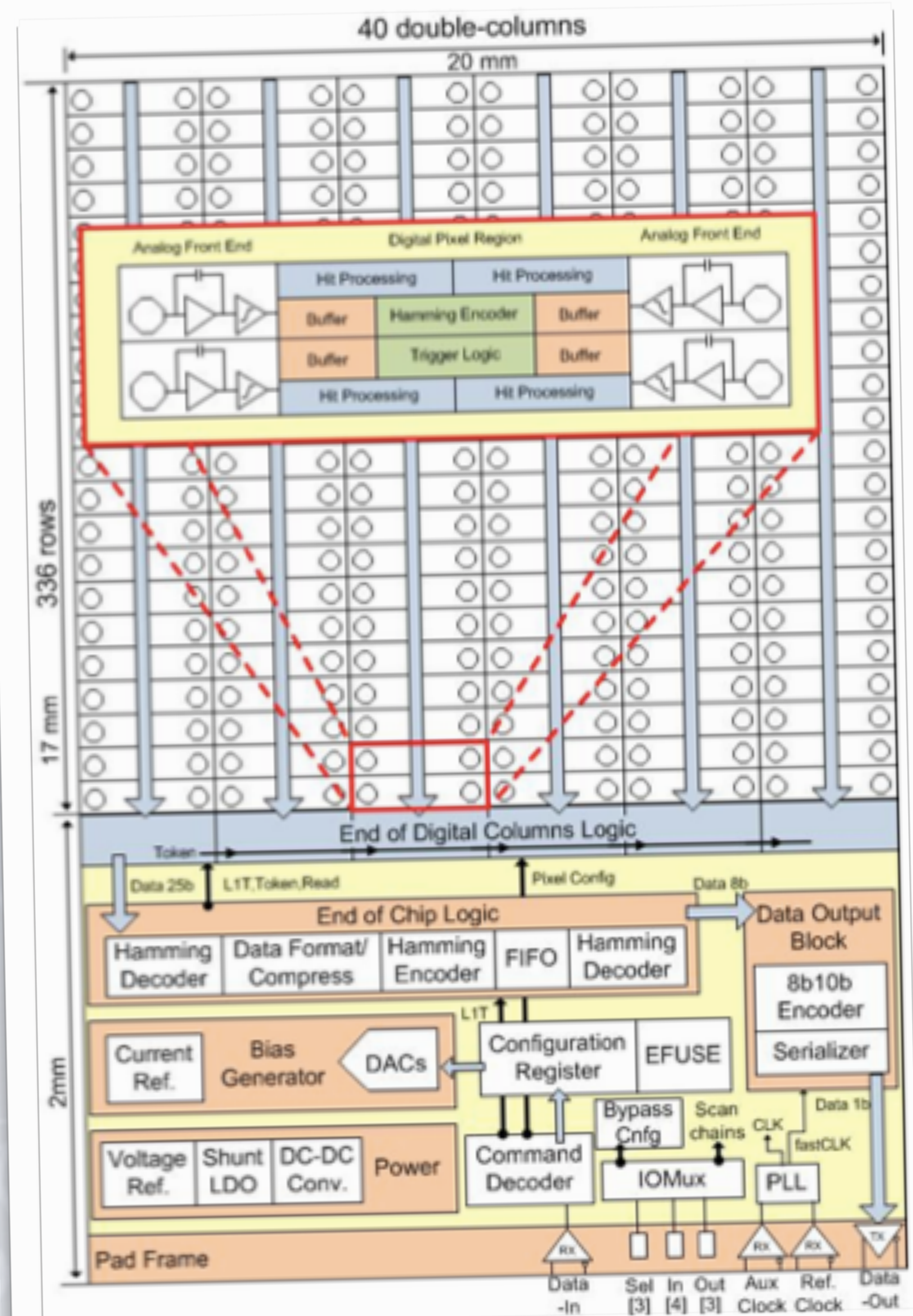

## Irradiated 3D CNM

- $5 \cdot 10^{15}$ $n_{eq}/cm^2$
- 97.5% overall efficiency at 0°
- 99.0% overall efficiency at 15°

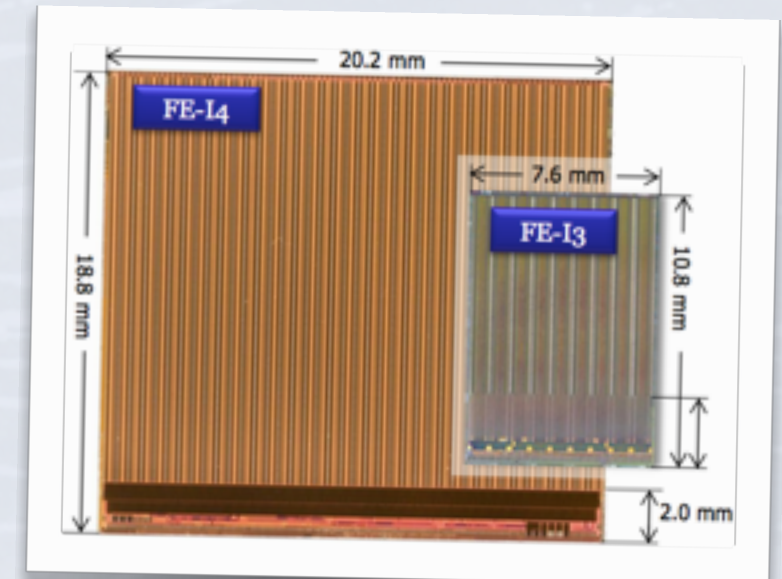
JINST 7 (2012) P11010

# New Readout Chip FE-I4






- ~ 2 x 2 $cm^2$
- 87M transistors
- 26880 pixels
- 89% active area



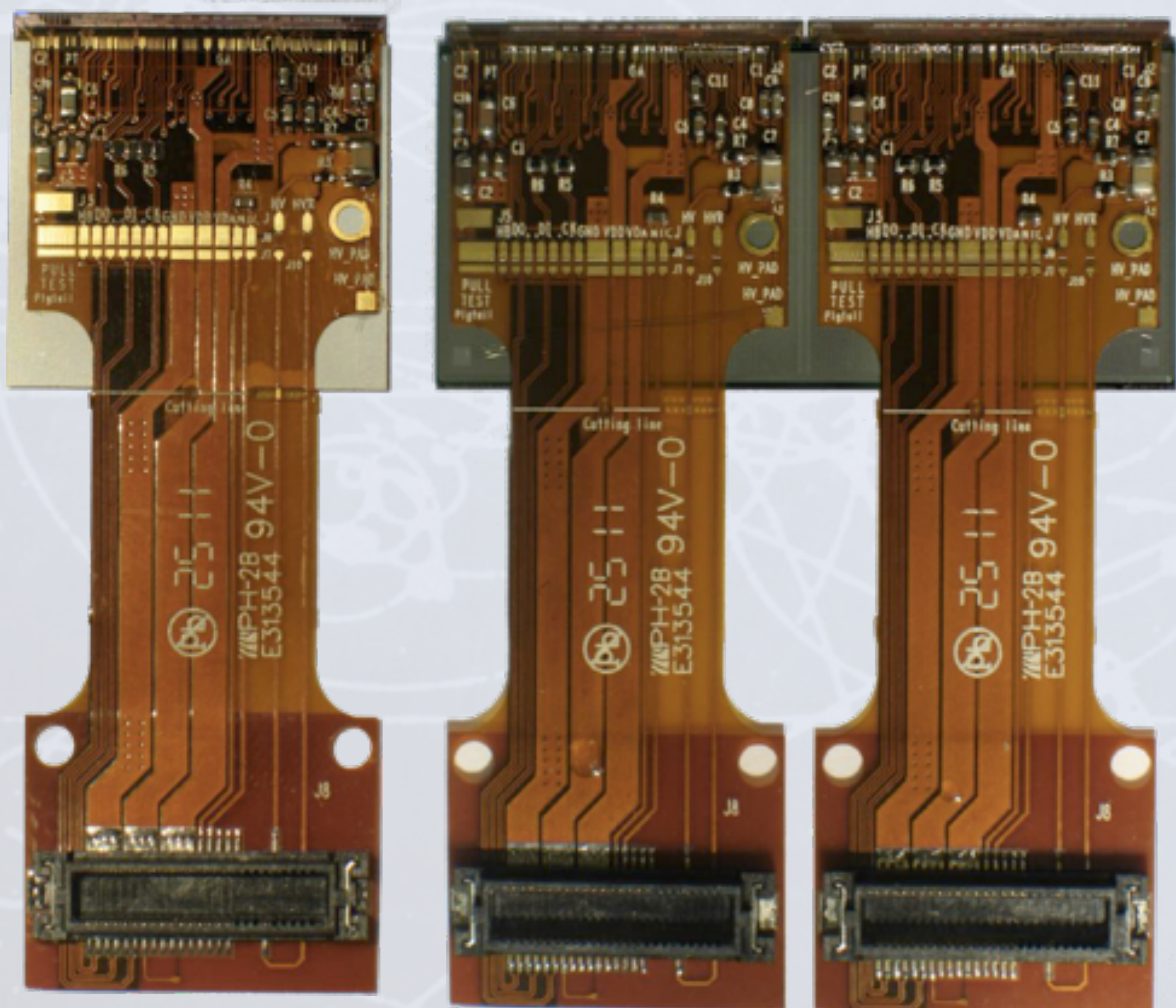

- 130nm front-end chip can cope with higher radiation levels (750 MRad) and larger occupancies
- Local hit storage (four pixel region) supports higher occupancies without saturation
- Balanced outputs allow higher data transmission rates
- Low drop out regulators (LDO)

# IBL Modules and Staves

Silicon & Kapton

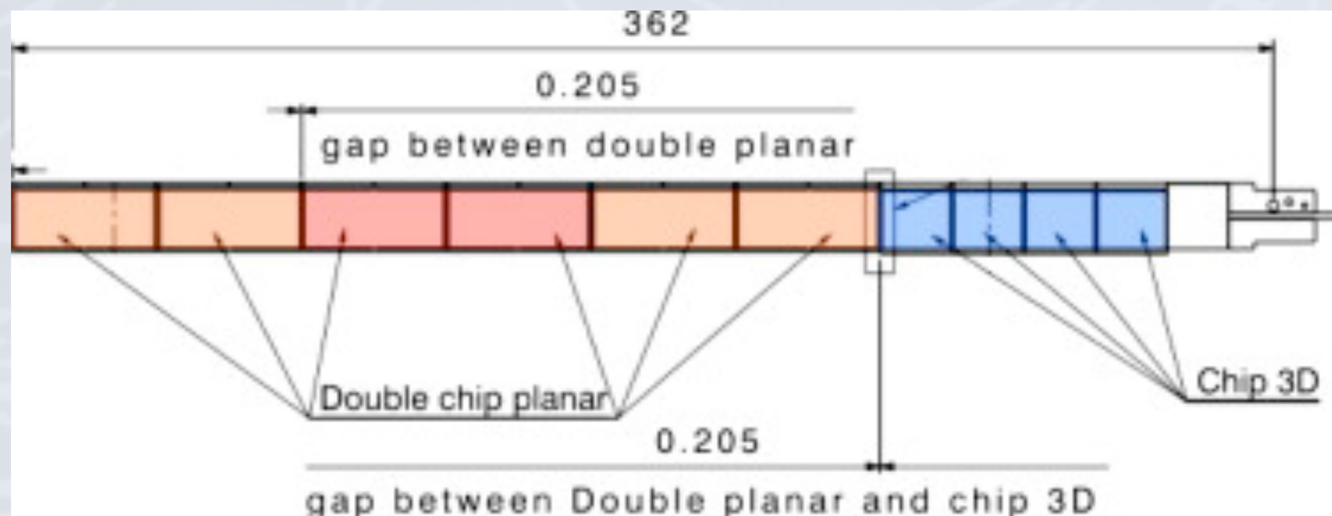
Single Chip (SC) 3D

Double Chip (DC) Planar



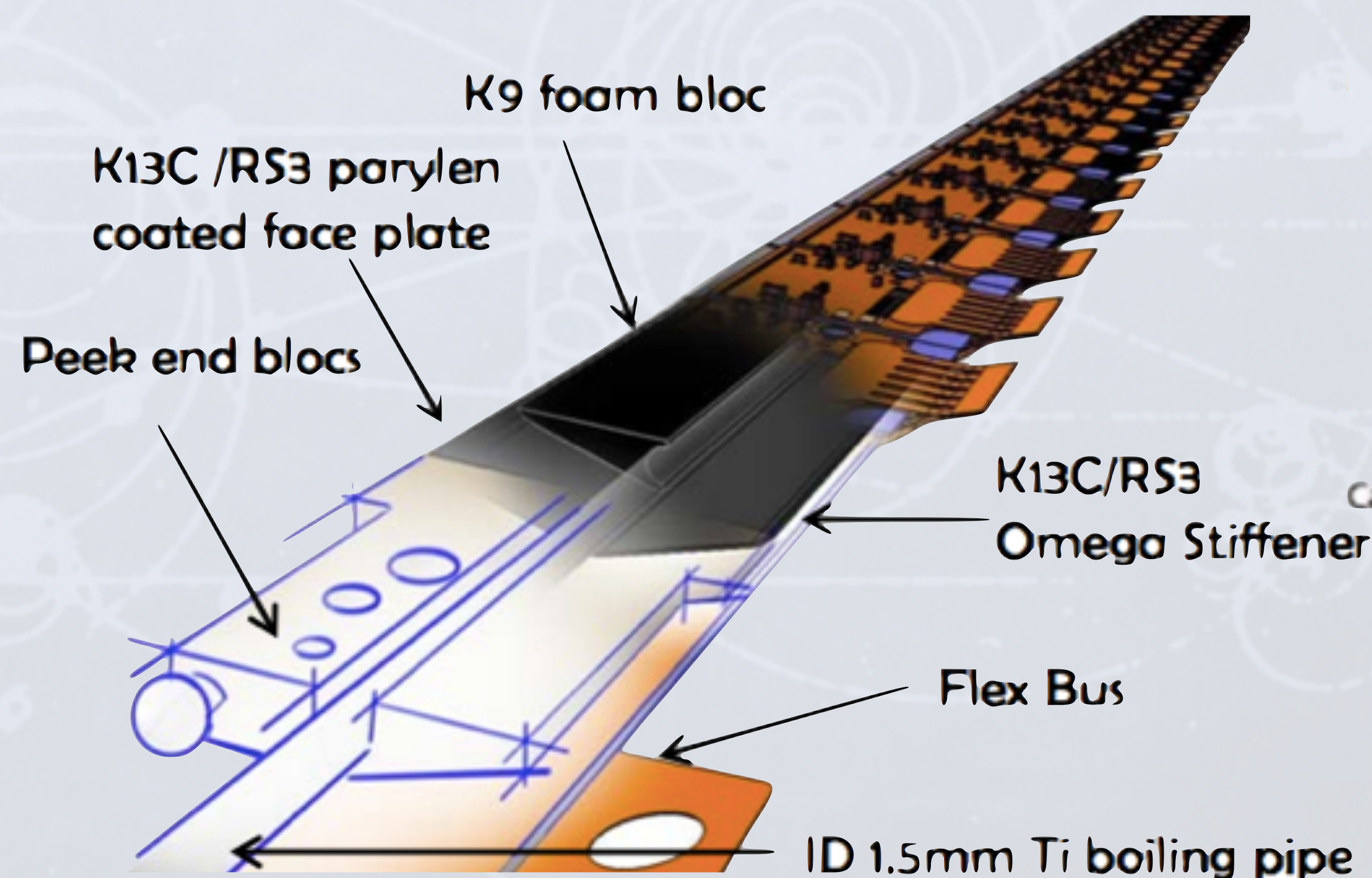
- Bare module assembly (IZM, Berlin)
  - 150 µm thinning of FE-I4 with glass handling wafer
  - Dicing
  - Bump bonding of sensor and FE(s)
  - Laser release of glass
- Module assembly (Bonn & Genova)
  - Flex to bare module glueing
  - Wire bonding
  - Quality assurance & burn-in

# IBL Modules and Staves CARBON & TITANIUM

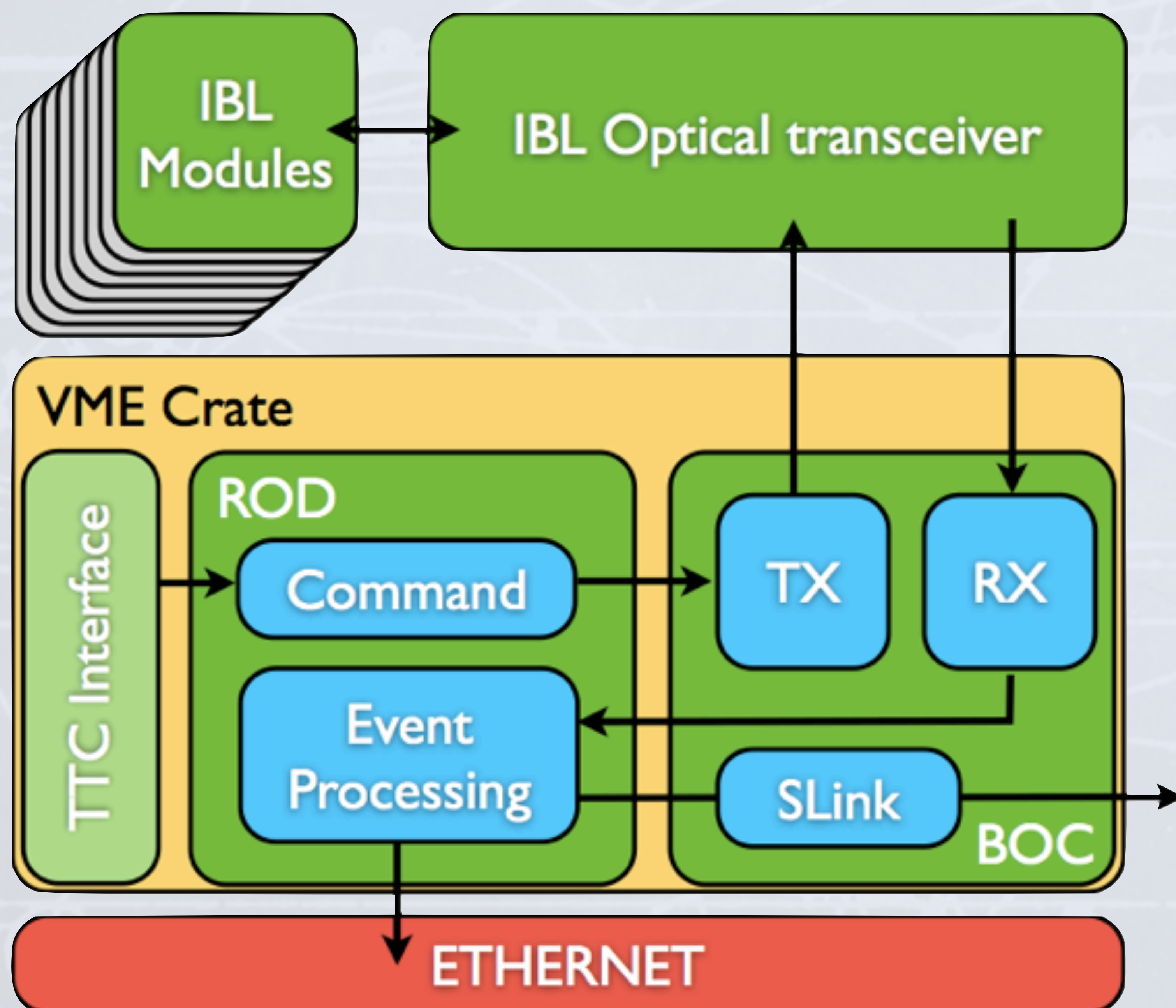



- 14 staves a 32 FE-I4s
- 25% 3D single chip (SC) modules
- 75% planar double chip modules (DC)
- 2DC/4SC = power group

- carbon foam with carbon fibre laminate bare stave
- embedded Titanium $CO_2$ cooling tube
- Flex PCB bus with Cu (signal & HV) & Al (power) lines
- Flex module wings
- Module loading in Geneva

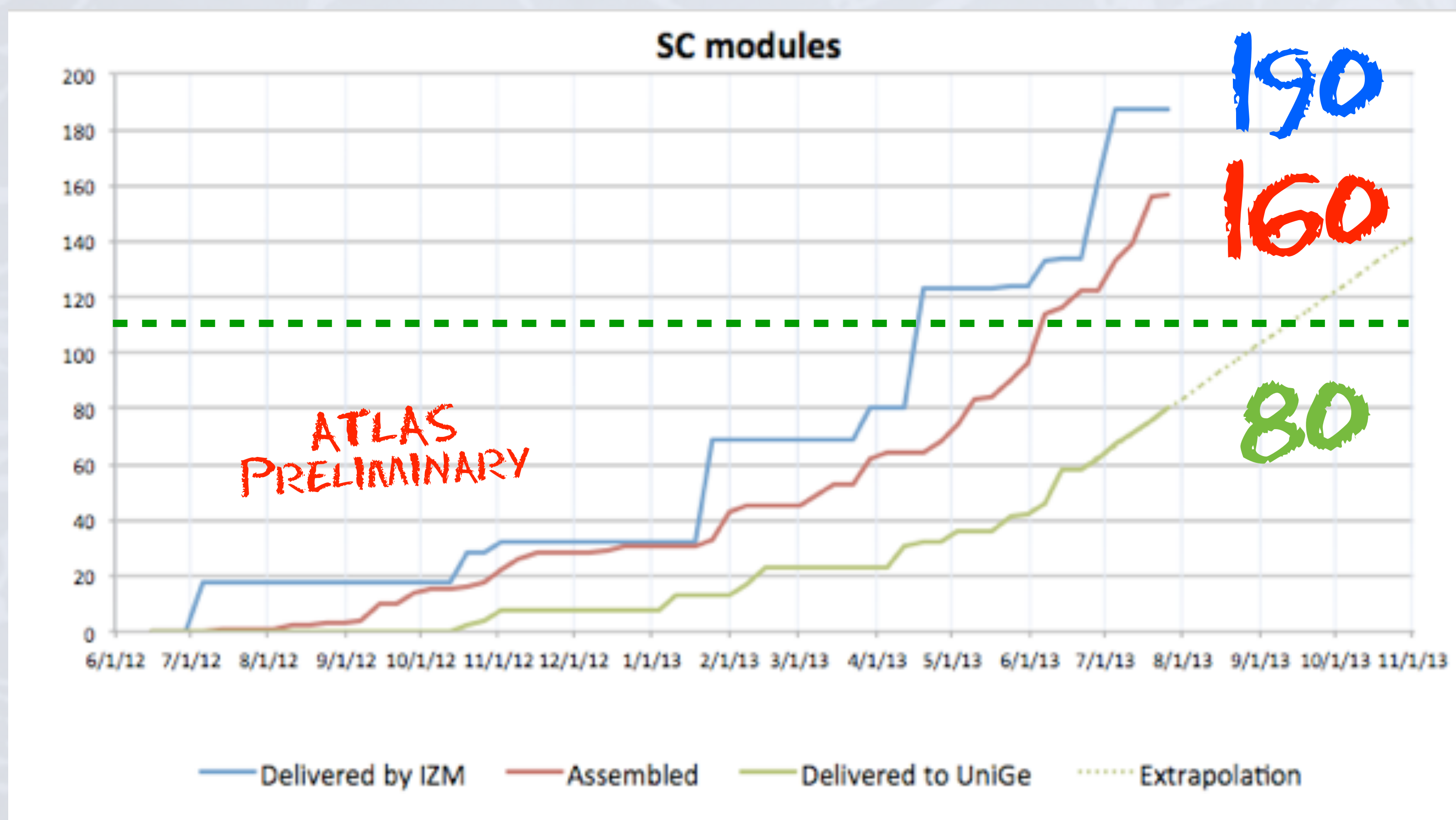


# Readout Structure RODs & BOCs

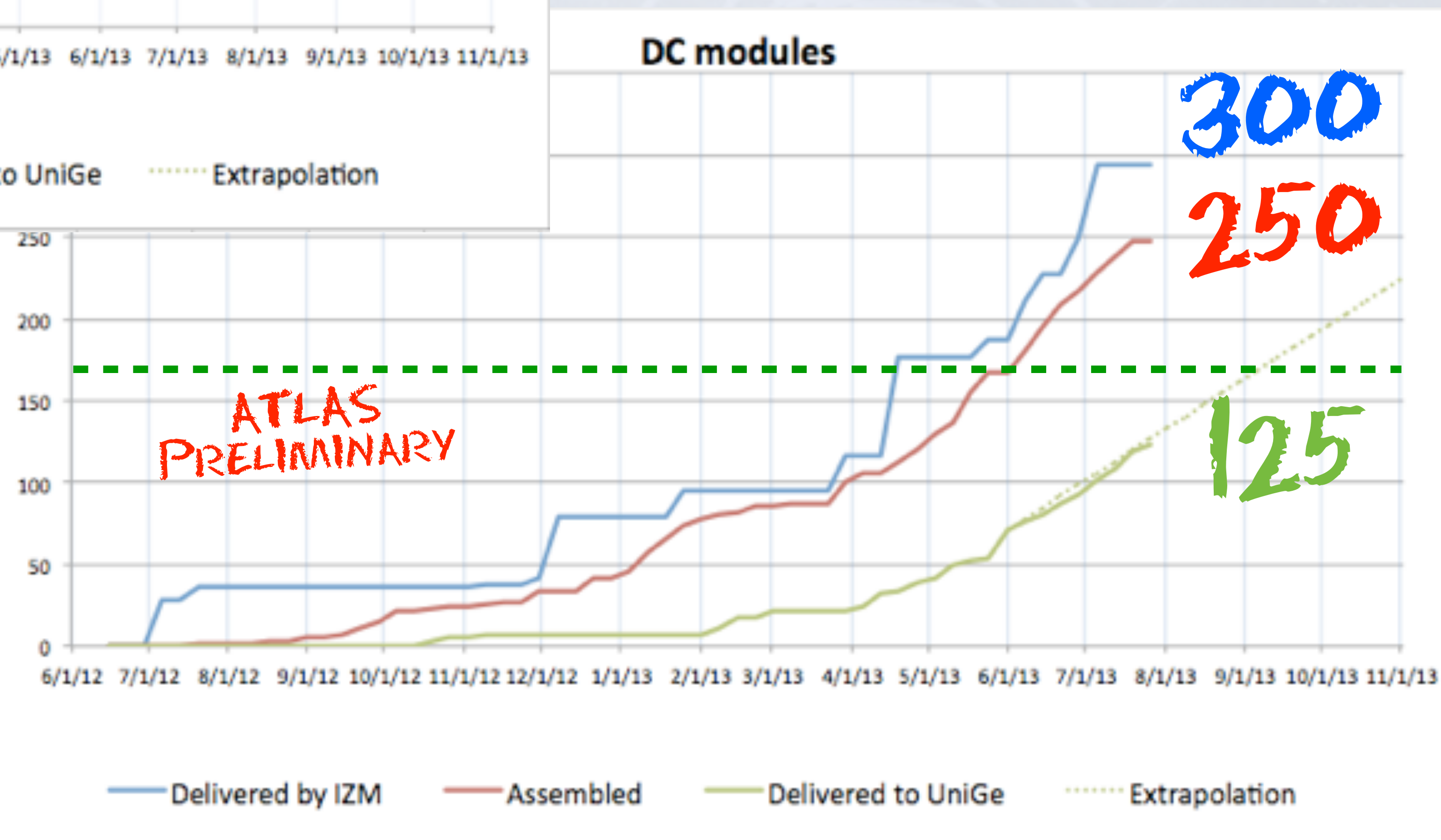



- New Readout Driver (ROD), new Back-of-Crate Card (BOC)
- Higher data flow density, ~ 6Gbit/s per card
- Off-the-shelve transceiver components for detector communication
- Ethernet base-layer for control and calibration to overcome VME bottleneck

# Module Production BONN & GENOVA



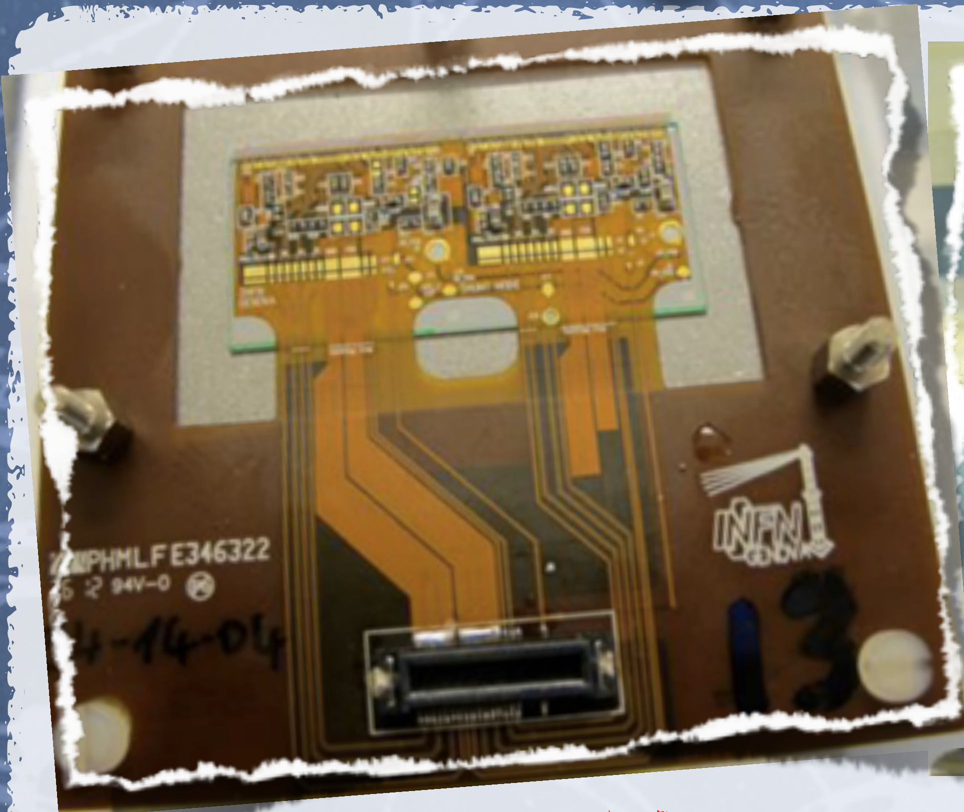

- Module production more than half way done (of 168+112 total modules)
- Should be finished in September



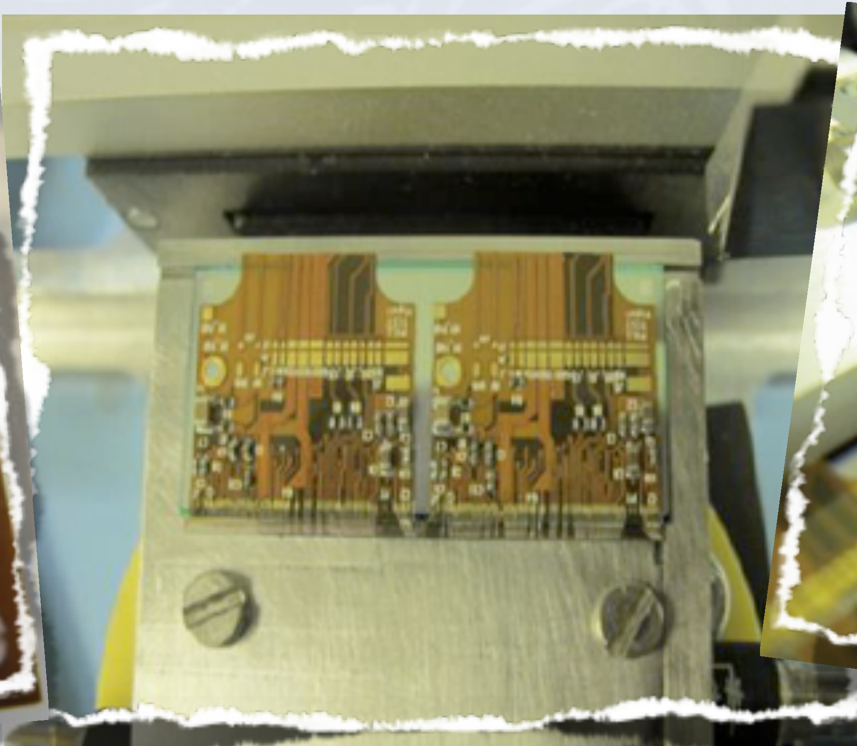

- Assembly test at 15˚C
- 10x -40...+40˚C thermal cycling during burn-in
- Qualification at -20˚C
- Ranking

# Stave Loading GENEVA

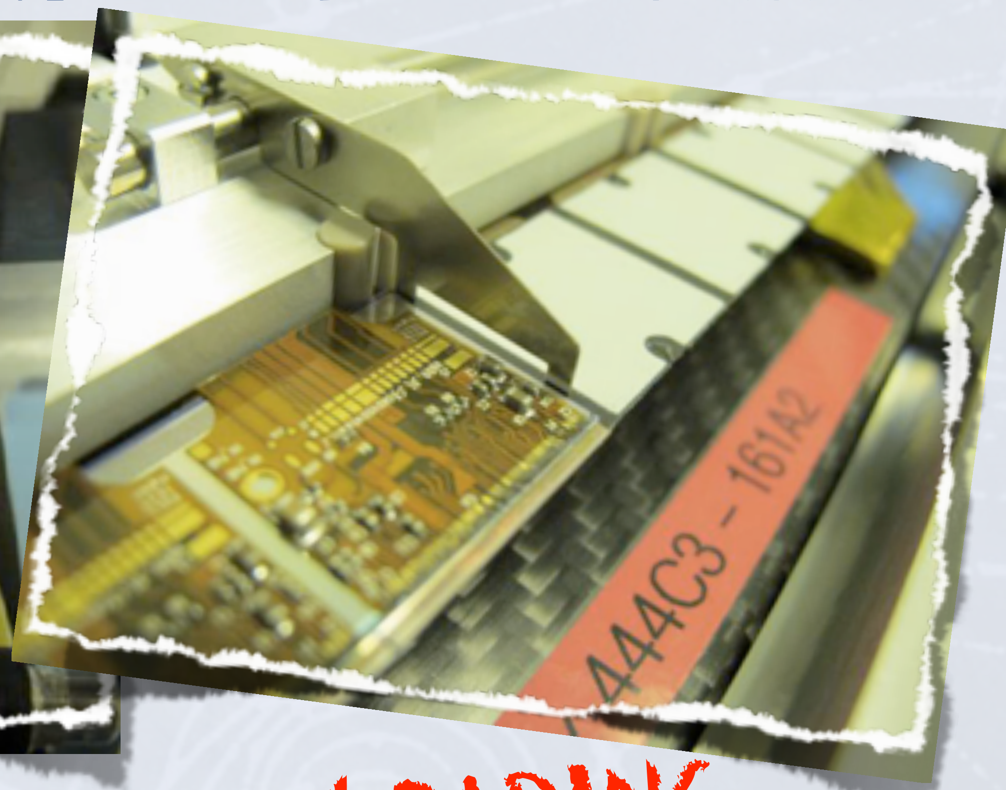




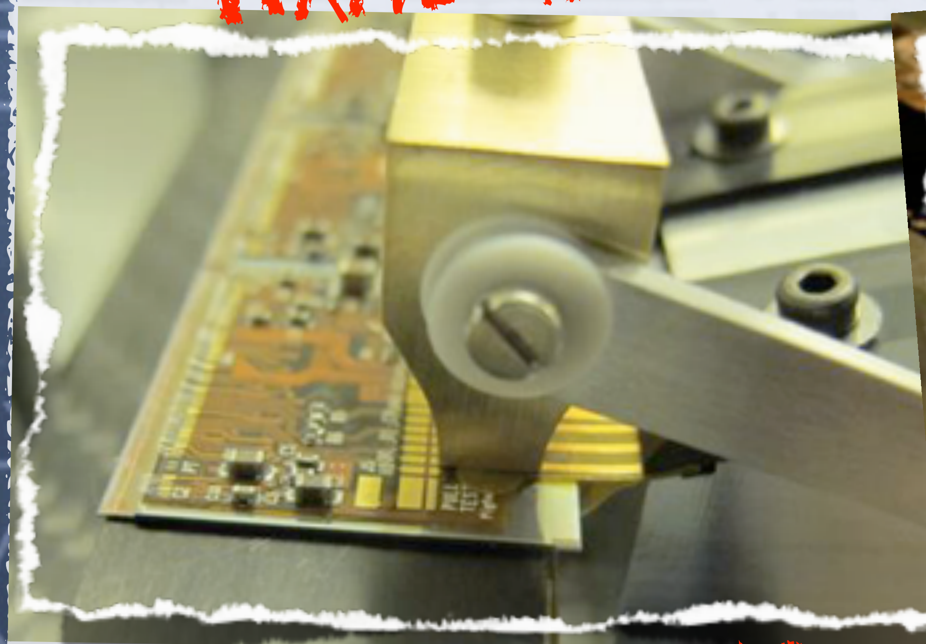
Handling



Guillotine



Loading



Wing Bending

Wire Bonding

Wire Pull Test

# Stave Quality Assurance AT CERN

- Reception tests (10˚C)
  - Communication (eye diagrams, register tests)
  - Power up studies
  - Comparison with Geneva results
  - Sensor IVs & warm tunings

- Operation tuning (-20˚C)
  - 10 TOT @ 16 ke$^-$
  - 3, 2.5, 2, 1.5 ke$^-$ threshold
  - Noisy and stuck pixel masks

- Operation (-20˚C)
  - $^{241}$Am and $^{90}$Sr source scans with self-trigger
  - Cosmic run (with trigger scintillator)
  - Double trigger
  - ...

# Highlights from the Quality Assurance STAVE

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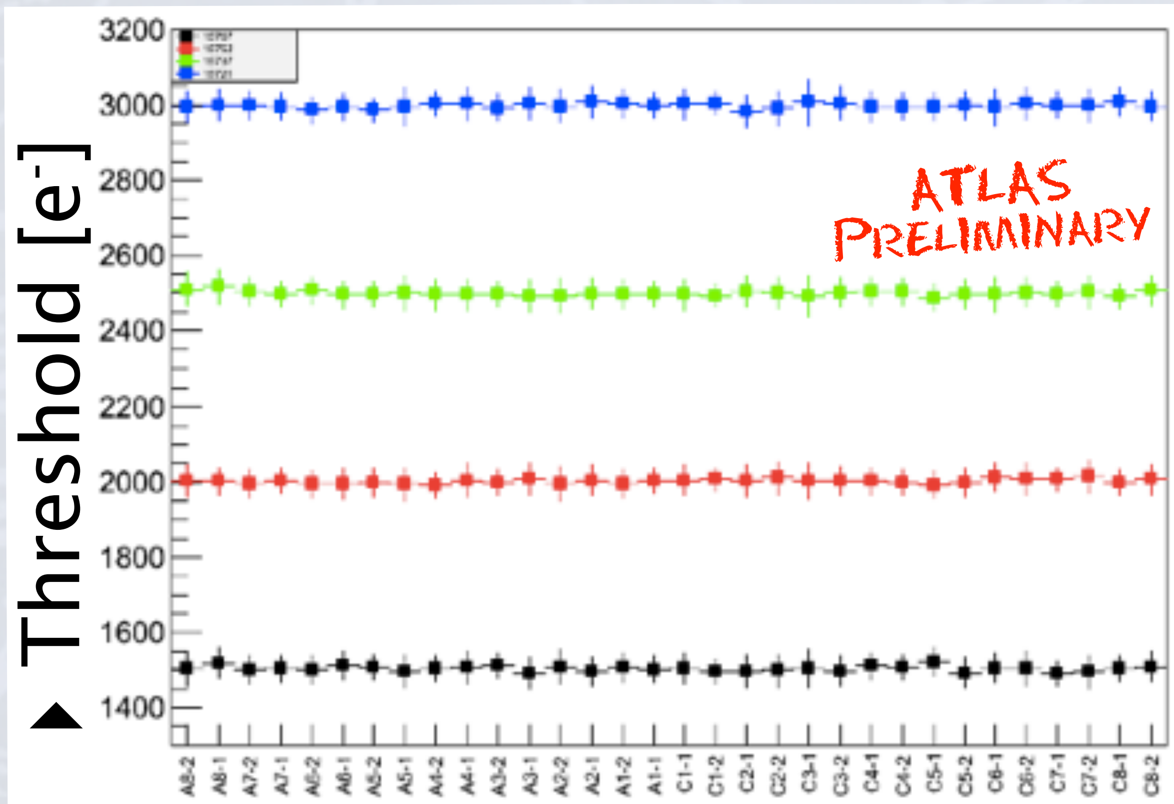
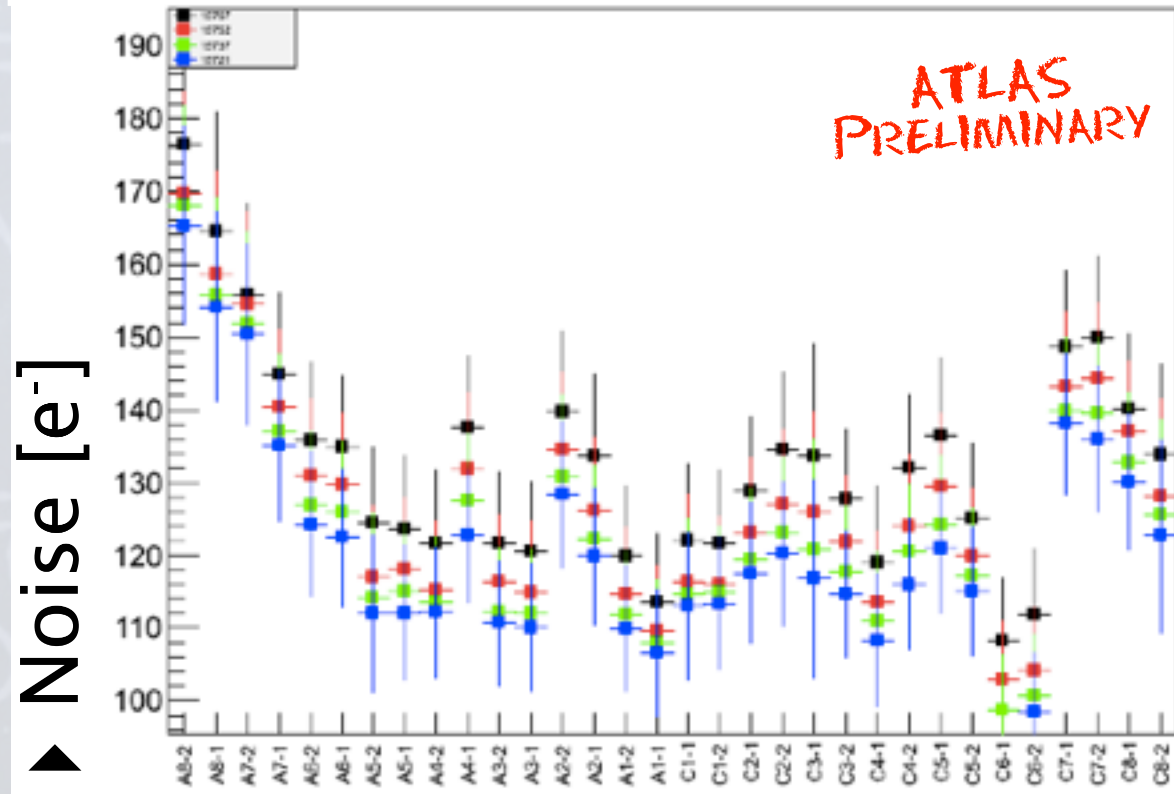
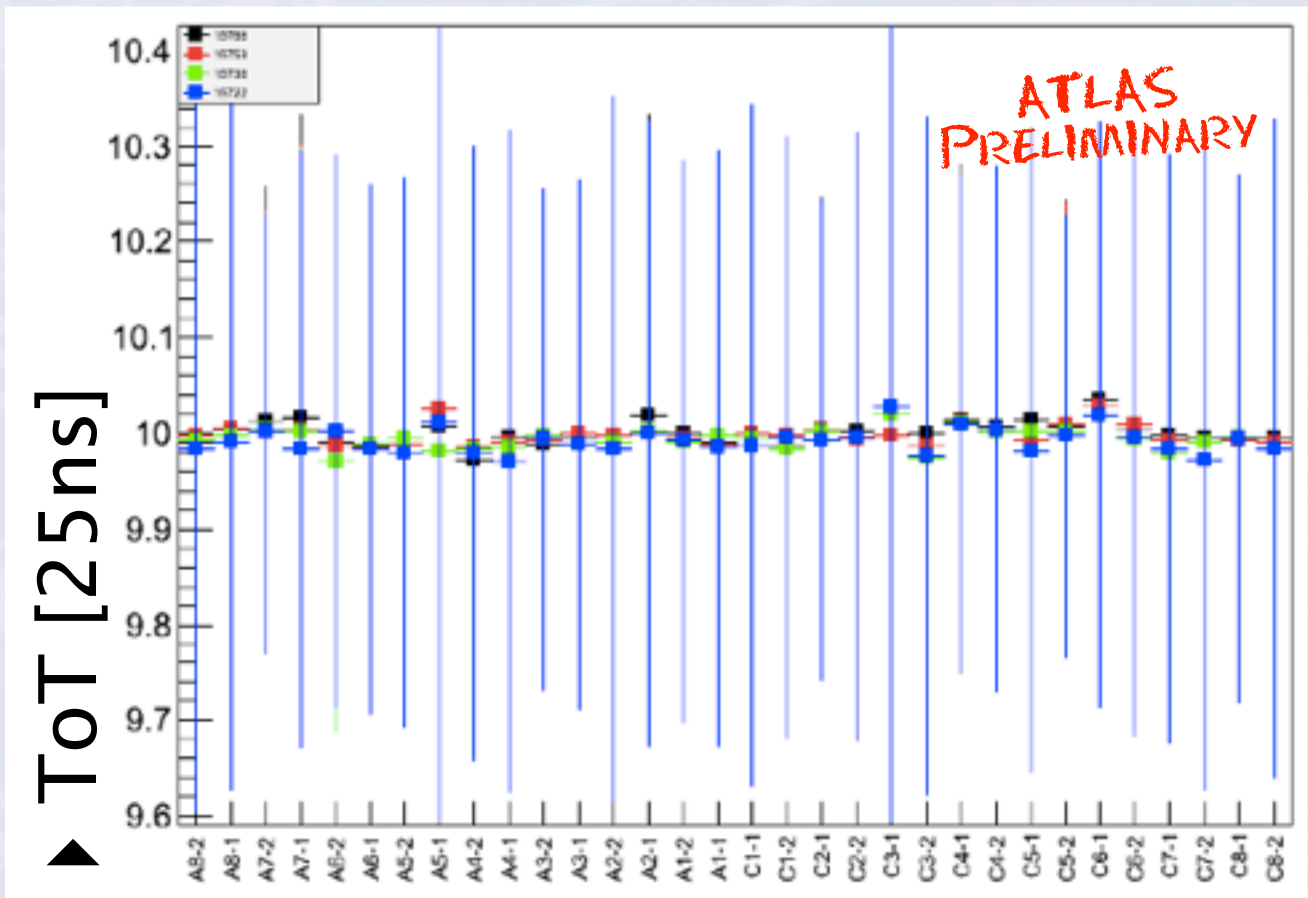
CERN





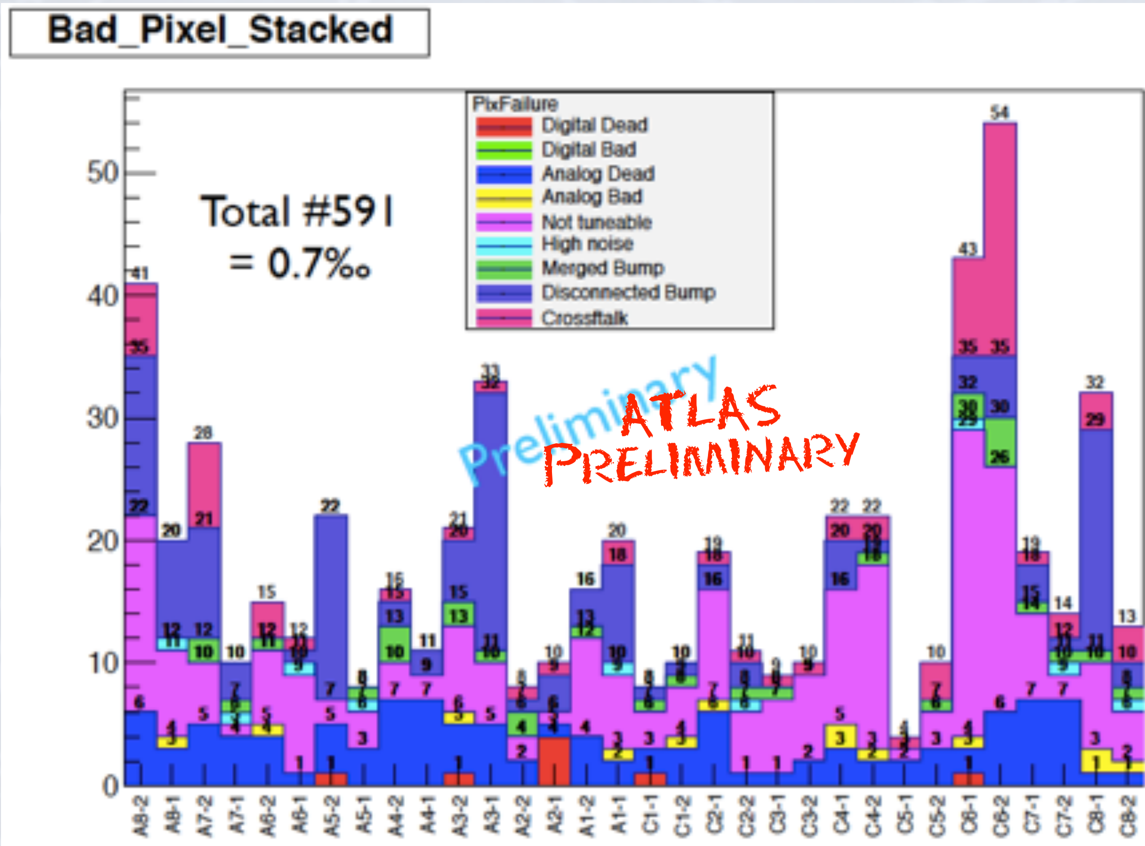

- 8 Staves assembled and 6 fully qualified up to now

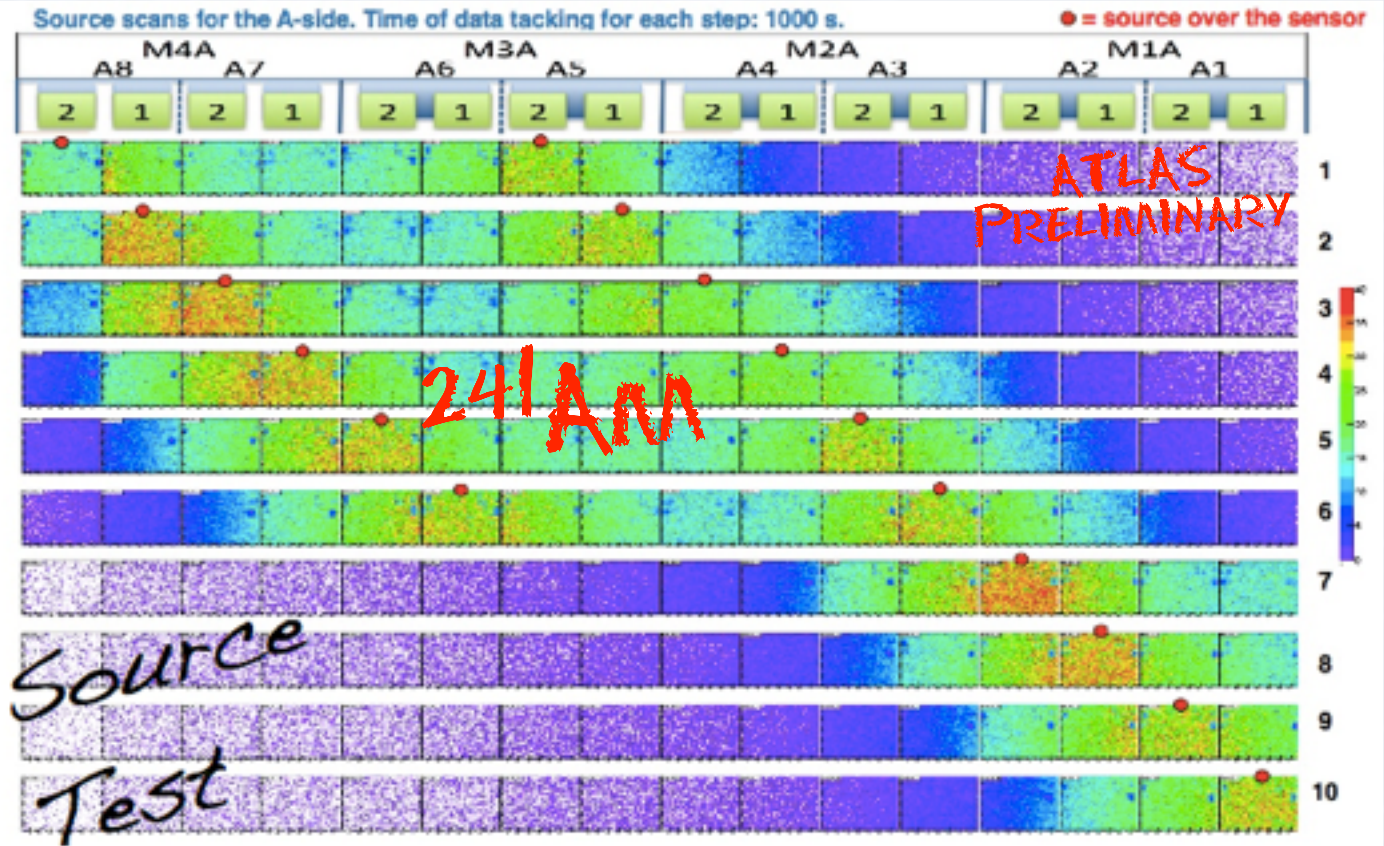
3000e-
2500e-
2000e-
1500e-

Threshold with 10 ToT at 16ke-

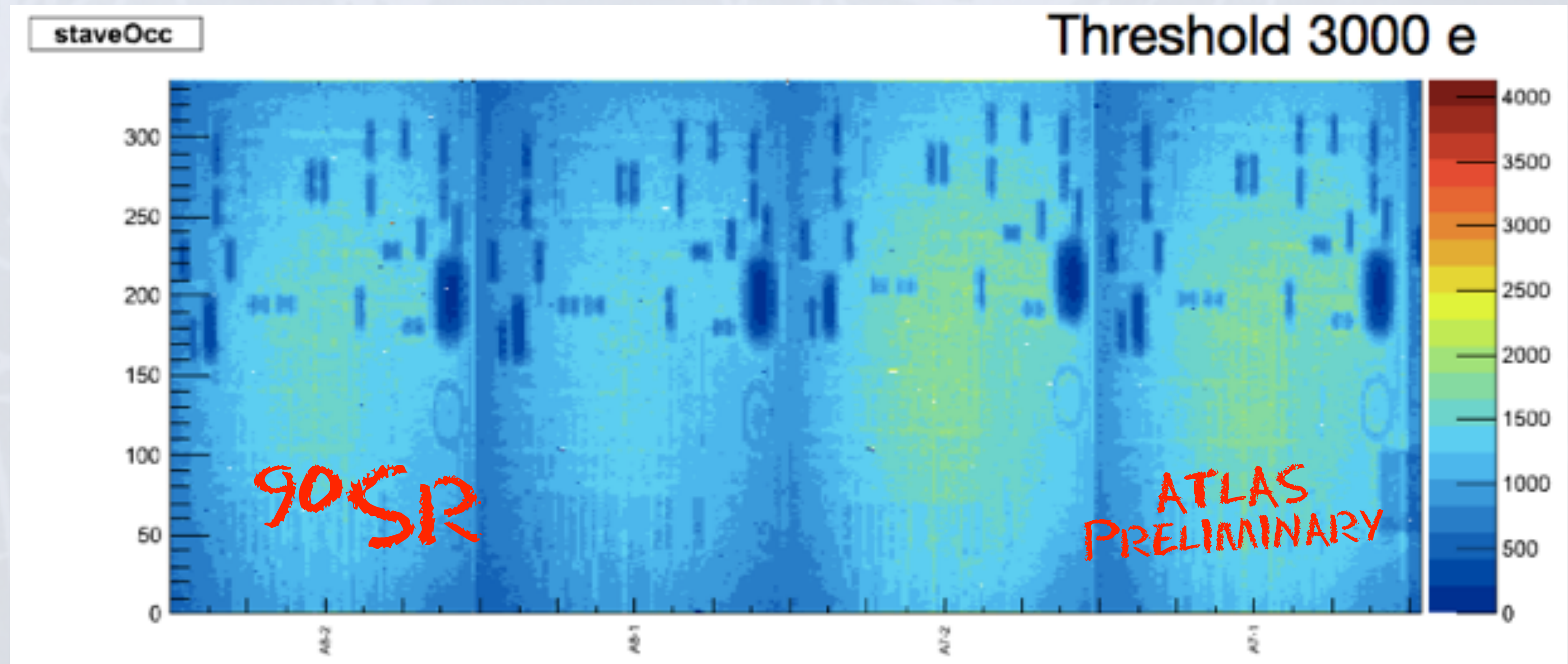
# Highlights from the STAVE Quality Assurance






- Source scans with $^{241}$Am & $^{90}$Sr as well as cosmics runs show pixel functionality and allow charge calibration



# IBL Stave Integration AT CERN

# Conclusions

## Summary

- New innermost ATLAS silicon layer using 3D and planar slim edge sensors
- Chip and sensor show good yields
- Module production and stave loading currently ongoing
- Stave integration about to start

## Outlook

- September: Finish module testing
- November: Finish stave loading and testing
- April 2014: Integration to Pixel Detector

# Backup Slide IV Curves